

	L #	Hits	Search Text	DBS	Time Stamp
1	L1	893	sapphire near12 (source or target)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 19:26
2	L8	583030	(sputter\$4 evaporat\$3 cosputter\$4 coevaporat\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 19:27
3	L15	286	1 and 8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 19:27
4	L22	286190	("Al.sub.2" adj "O.sub.3") or Al2O3 or alumina	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 19:28
5	L29	12463	22 near15 deposit\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 19:29
6	L36	3	1 same 8 same 29	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 19:30

	L #	Hits	Search Text	DBs	Time Stamp
1	L1	2932	((silicon adj monoxide) or SiO) with (source target)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 16:41
2	L8	8812	((("Al.sub.2" adj "O.sub.3") or Al2O3 or alumina or sapphire) with (source target)) or ((aluminum adj oxide) with (source target))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 16:41
3	L15	172013	(ion ionic ionized electron) adj2 (gun beam)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 11:27
4	L22	19	1 and 8 and 15	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 11:27
5	L29	201671	(plural multiple several two three separate) near4 (target source)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 16:39
6	L36	583030	(sputter\$4 evaporat\$3 cosputter\$4 coevaporat\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 16:40
7	L43	18893	29 and 36	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 15:31
8	L50	3890	43 and (apparatus).ti,ab.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 15:32
9	L57	1	50 and 1 and 8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 15:33
10	L64	124	50 and 8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 15:45
11	L71	18	50 and 1	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 15:33
12	L78	83	64 and (silicon or si)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/02/22 15:46
13	L85	1	"5108574".PN.	USPAT	2002/02/22 16:06
14	L86	47374	(plural multiple several two three separate) near4 (target source)	USOCR	2002/02/22 16:40
15	L87	151078	(sputter\$4 evaporat\$3 cosputter\$4 coevaporat\$3)	USOCR	2002/02/22 16:40
16	L88	2545	86 and 87	USOCR	2002/02/22 16:40
17	L89	1274	((("Al.sub.2" adj "O.sub.3") or Al2O3 or alumina or sapphire) with (source target)) or ((aluminum adj oxide) with (source target))	USOCR	2002/02/22 16:41
18	L90	963	((silicon adj monoxide) or SiO) with (source target)	USOCR	2002/02/22 16:42
19	L91	4	88 and 89 and 90	USOCR	2002/02/22 16:42